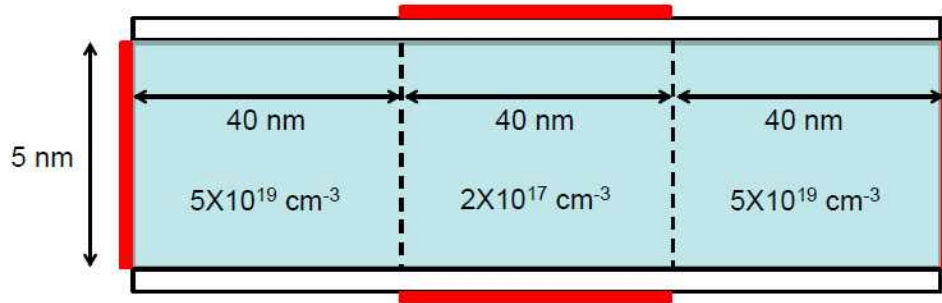


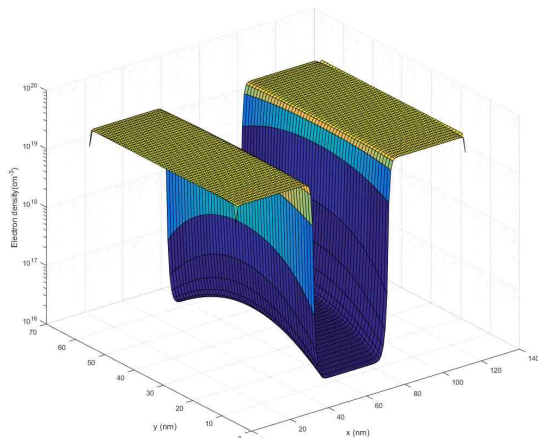
Double gate structure

- Double-gate 5-nm-thick silicon & 0.5-nm-thick oxide at both sides
- 40-nm-long gate (Workfunction: 4.3 eV)

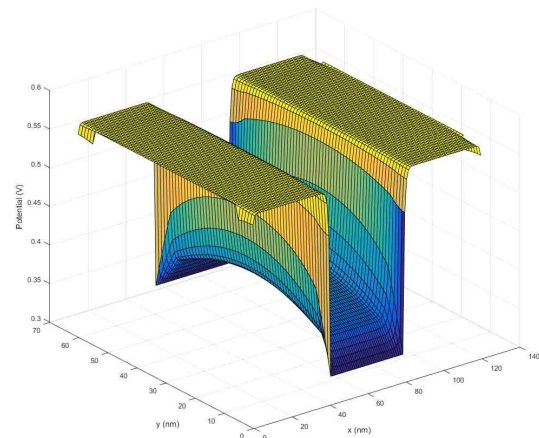


Step 1

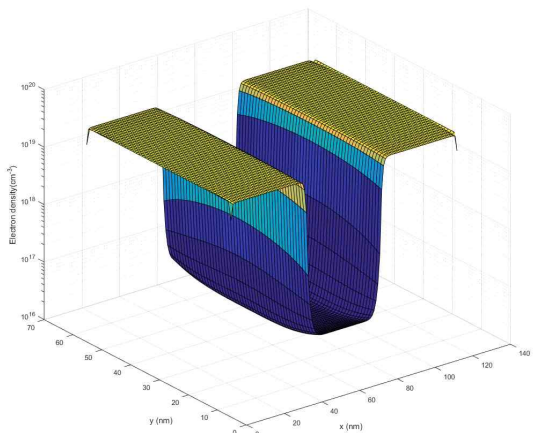
- Solve the nonlinear Poisson equation for the double-gate structure.
- $V_S = V_D = 0$ and V_G varies from 0 V to 1 V. (0.1 V step)



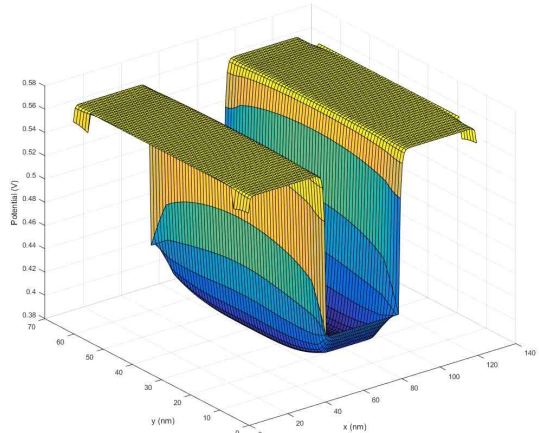
Electron density at $V_D = 0$ V



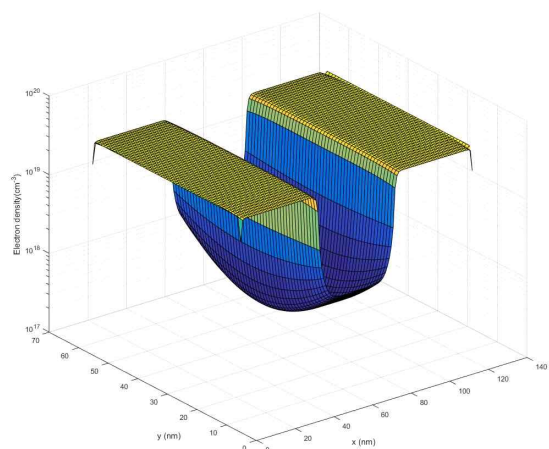
Potential at $V_D = 0$ V



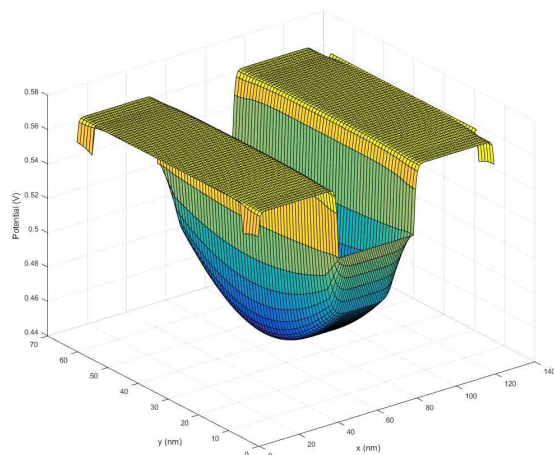
Electron density at $V_D = 0.1$ V



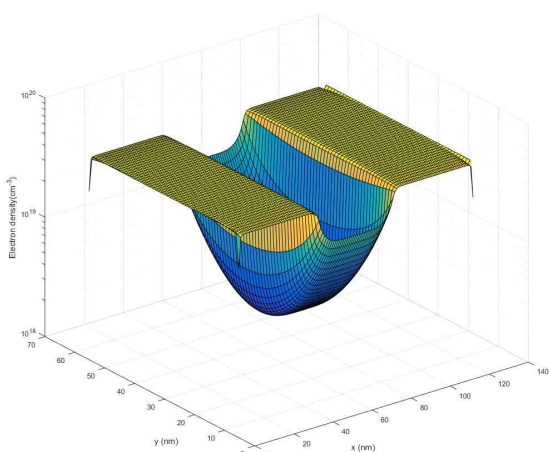
Potential at $V_D = 0.1$ V



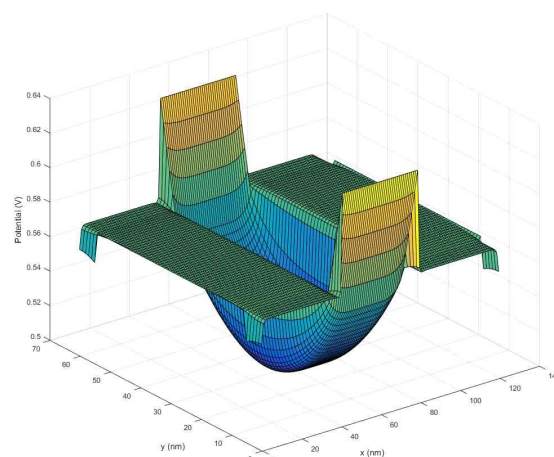
Electron density at $V_D = 0.2$ V



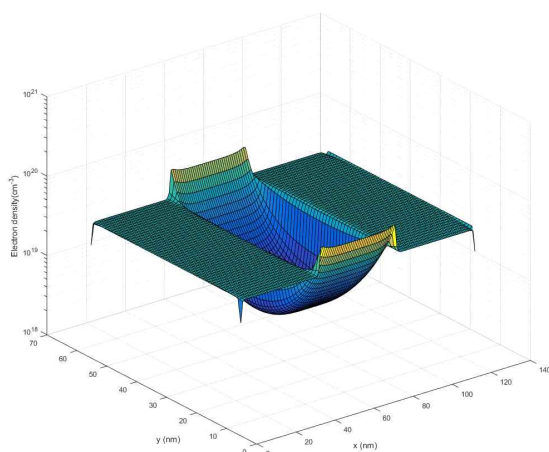
Potential at $V_D = 0.2$ V



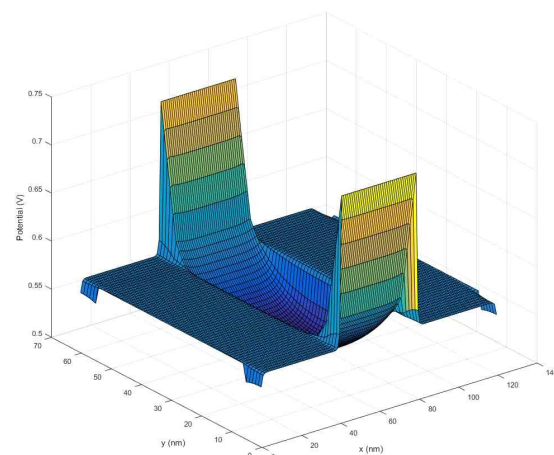
Electron density at $V_D = 0.3$ V



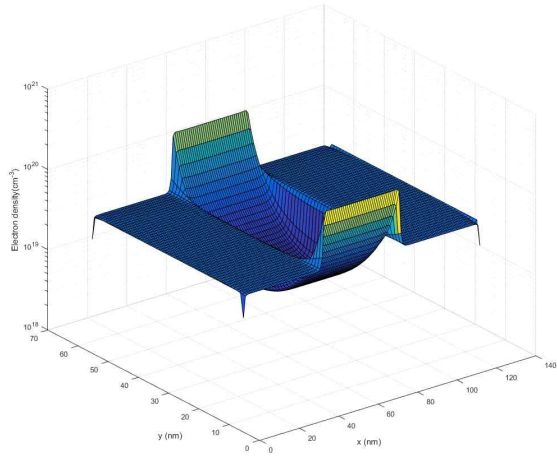
Potential at $V_D = 0.3$ V



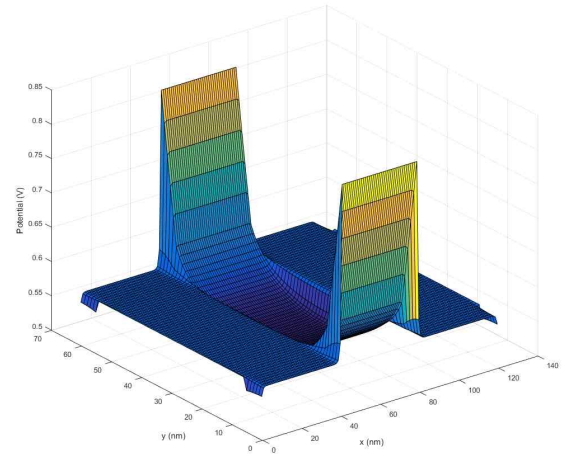
Electron density at $V_D = 0.4$ V



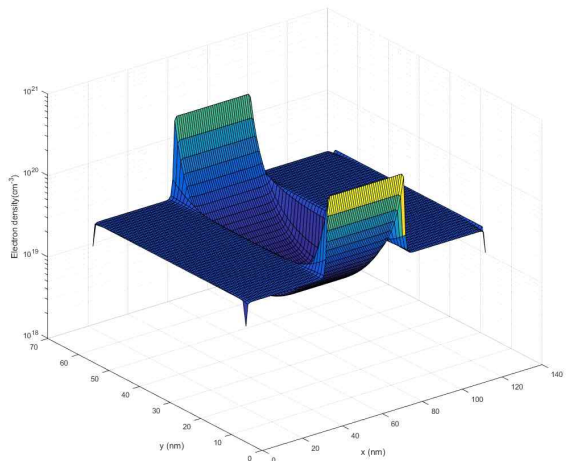
Potential at $V_D = 0.4$ V



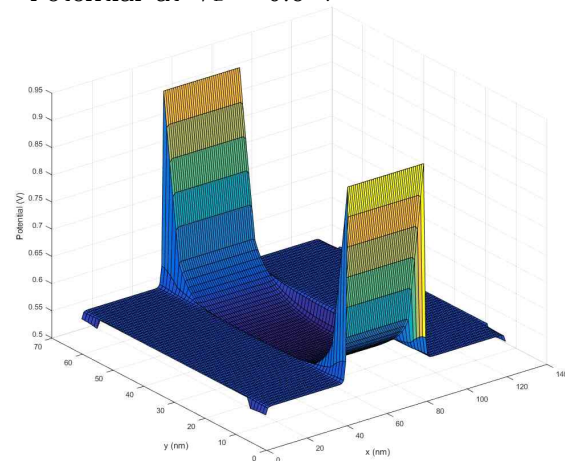
Electron density at $V_D = 0.5$ V



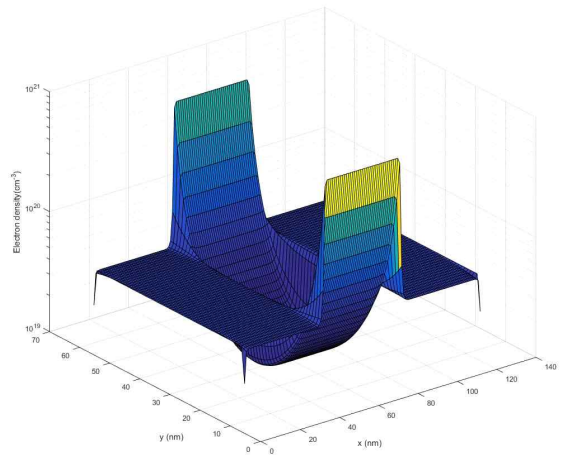
Potential at $V_D = 0.5$ V



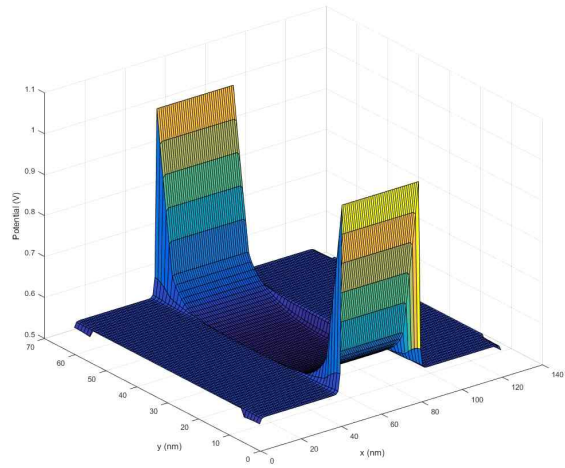
Electron density at $V_D = 0.6$ V



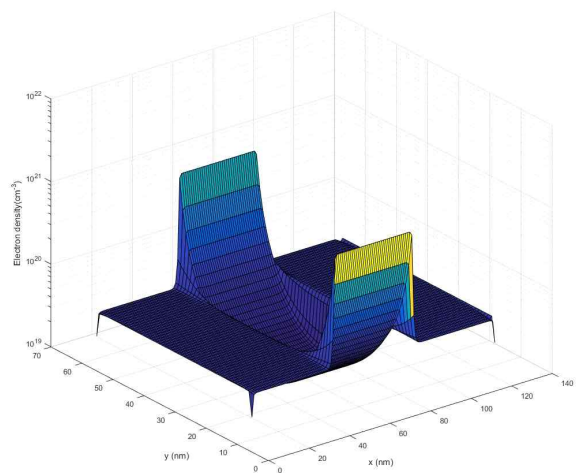
Potential at $V_D = 0.6$ V



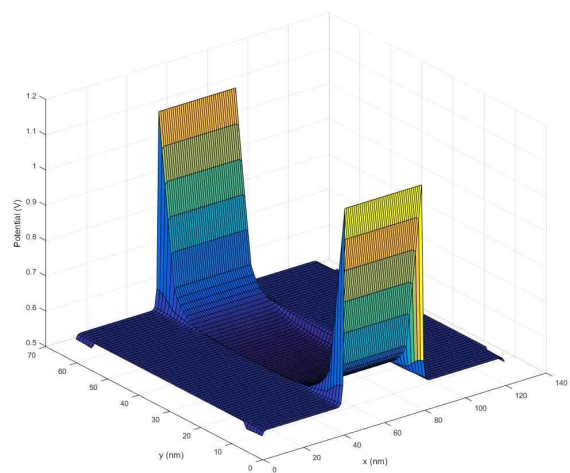
Electron density at $V_D = 0.7$ V



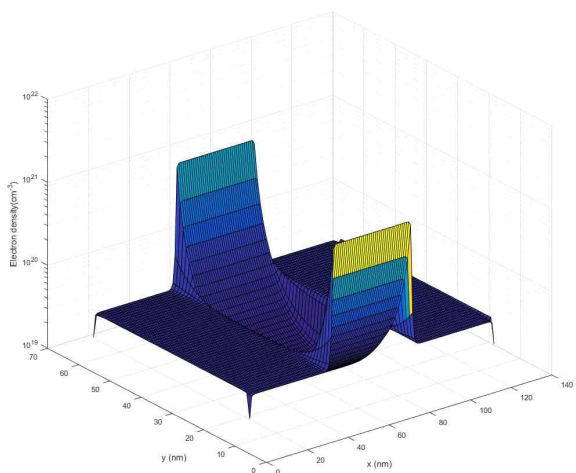
Potential at $V_D = 0.7$ V



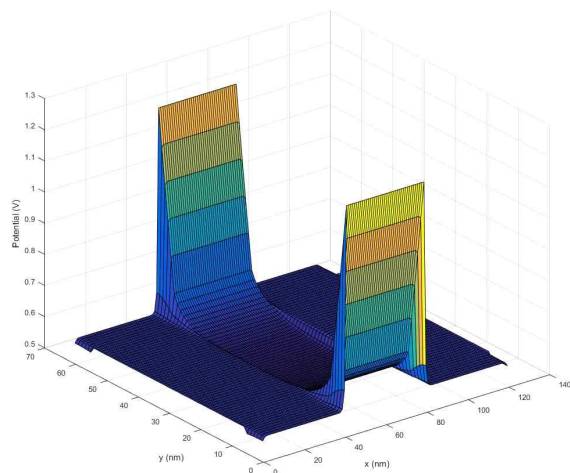
Electron density at $V_D = 0.8$ V



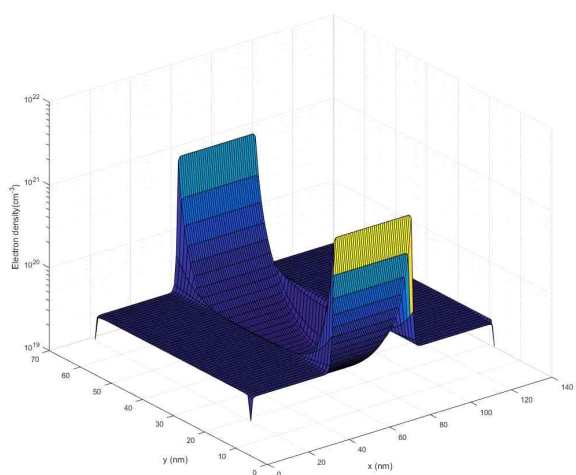
Potential at $V_D = 0.8$ V



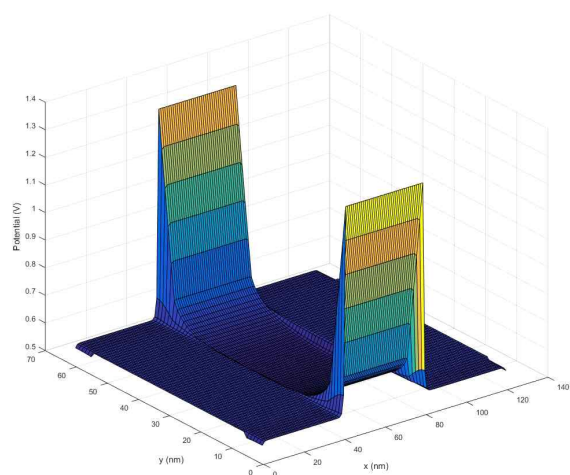
Electron density at $V_D = 0.9$ V



Potential at $V_D = 0.9$ V



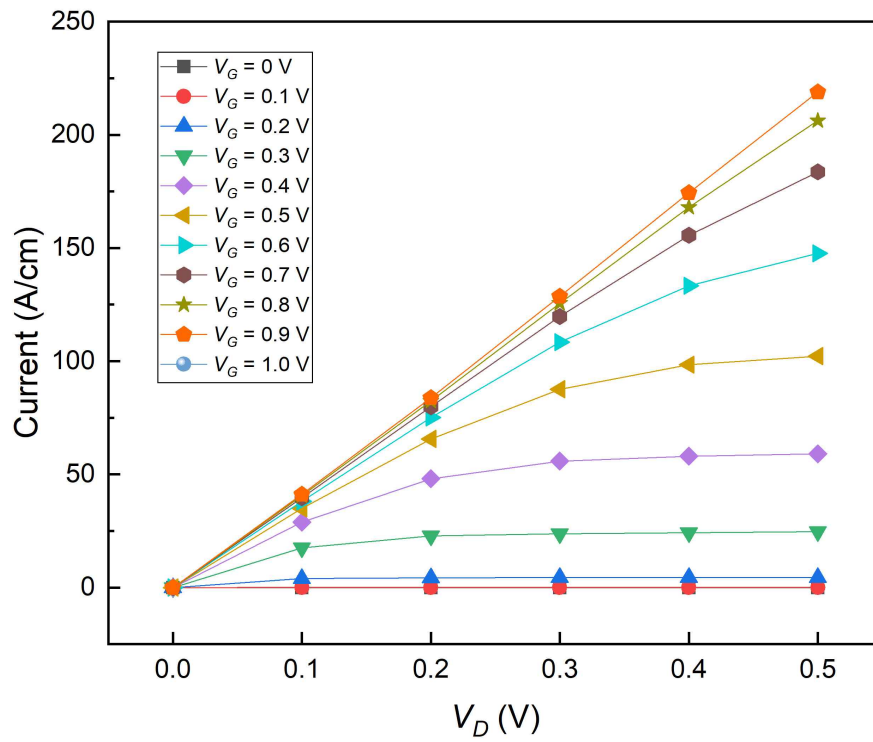
Electron density at $V_D = 1.0$ V



Potential at $V_D = 1.0$ V

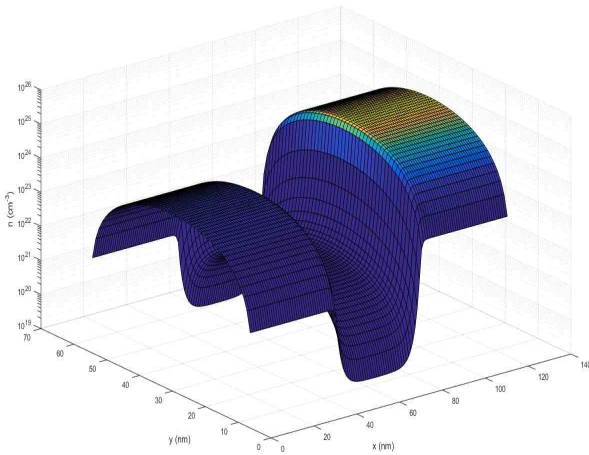
Step 2

- Solve the drift-diffusion equation for the double-gate structure.
- Self-consistent simulation is mandatory.
- $V_S=0$
- V_G varies from 0 V to 1 V. (0.1 V step)
- V_D varies from 0 V to 0.5 V. (0.1 V step)
- The electron mobility is assumed to be $1430 \text{ cm}^2/\text{V sec}$.

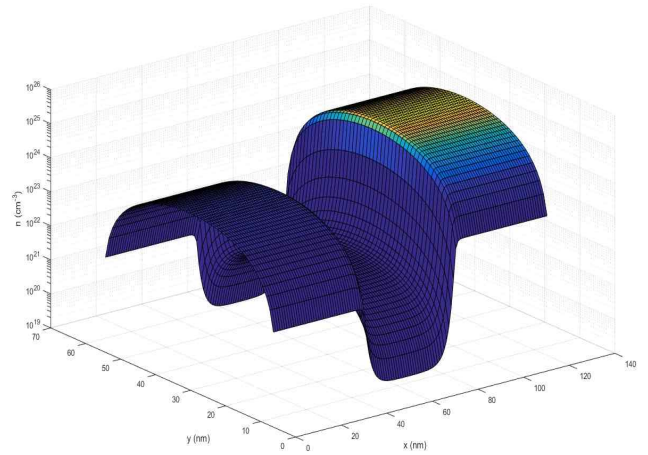


Step 3

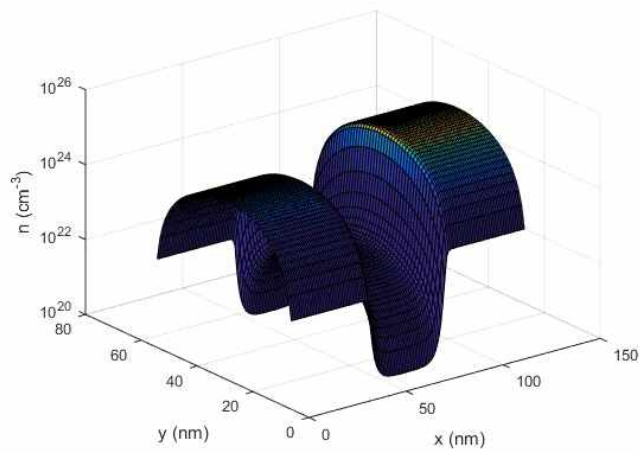
- Solve the Schrödinger equation.
- Use ϕ obtained in Step2.
- $V_S=0$
- Consider V_G of 0.1 V and 0.5 V.
- Consider V_D of 0.1 V and 0.5 V.
- Consider three different valleys.



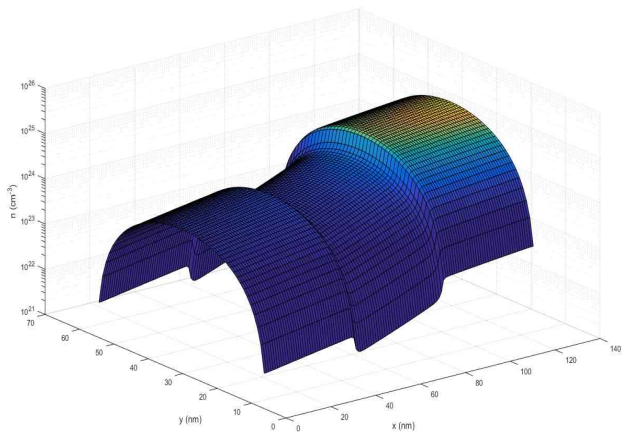
Electron density at $V_S = 0.1$ V and $V_G = 0.1$ V
 $m_{xx} = 0.91$; $m_{yy} = 0.19$; $m_{zz} = 0.19$



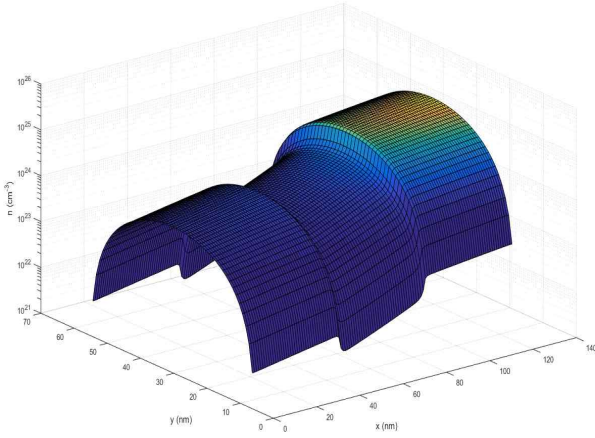
Electron density at $V_S = 0.1$ V and $V_G = 0.1$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.91$; $m_{zz} = 0.19$



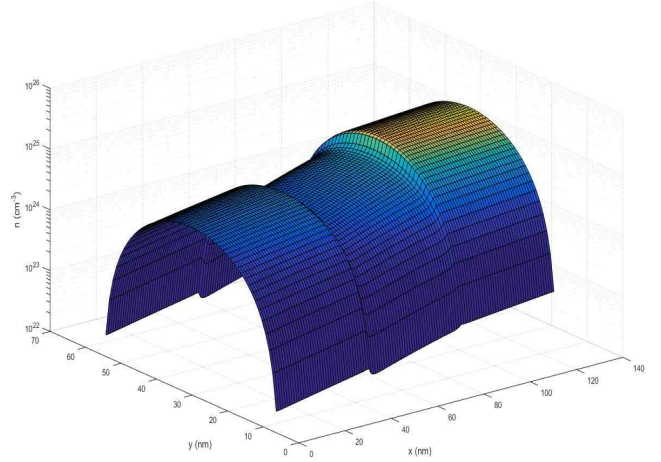
Electron density at $V_S = 0.1$ V and $V_G = 0.1$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.19$; $m_{zz} = 0.91$



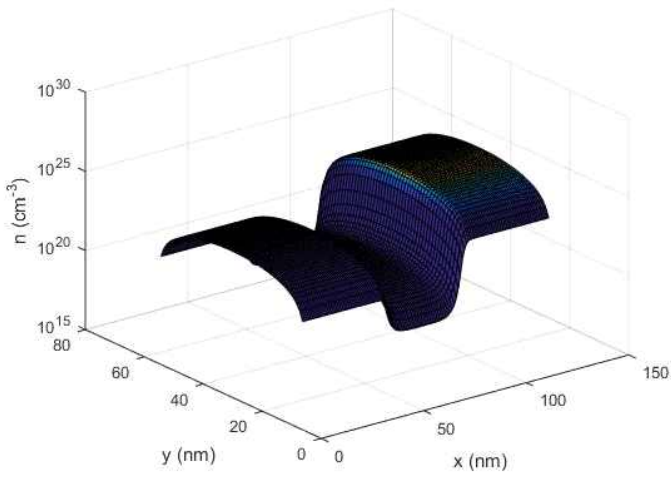
Electron density at $V_S = 0.1$ V and $V_G = 0.5$ V
 $m_{xx} = 0.91$; $m_{yy} = 0.19$; $m_{zz} = 0.19$



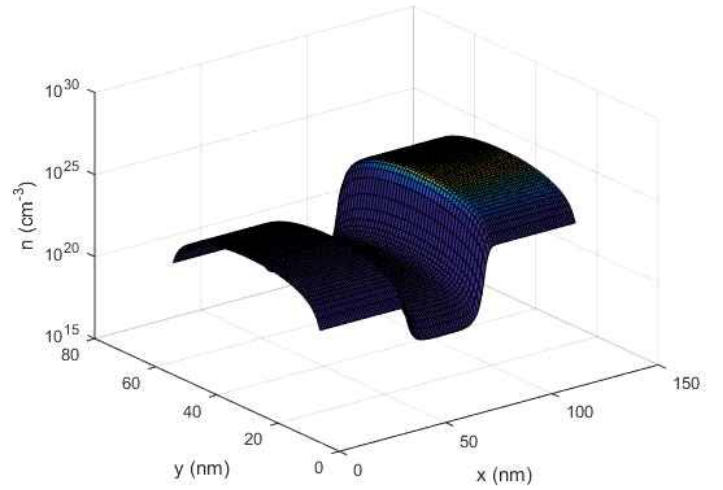
Electron density at $V_S = 0.1$ V and $V_G = 0.5$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.91$; $m_{zz} = 0.19$



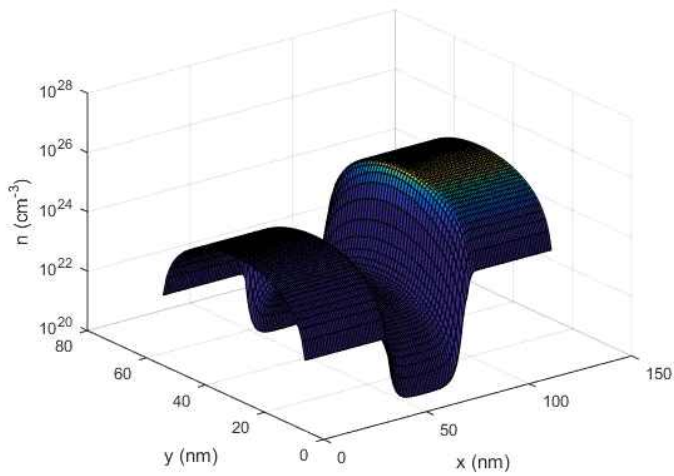
Electron density at $V_S = 0.1$ V and $V_G = 0.5$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.19$; $m_{zz} = 0.91$



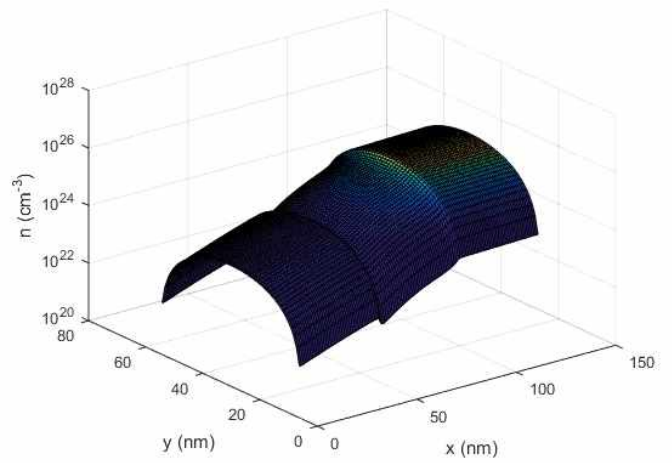
Electron density at $V_S = 0.5$ V and $V_G = 0.1$ V
 $m_{xx} = 0.91$; $m_{yy} = 0.19$; $m_{zz} = 0.19$



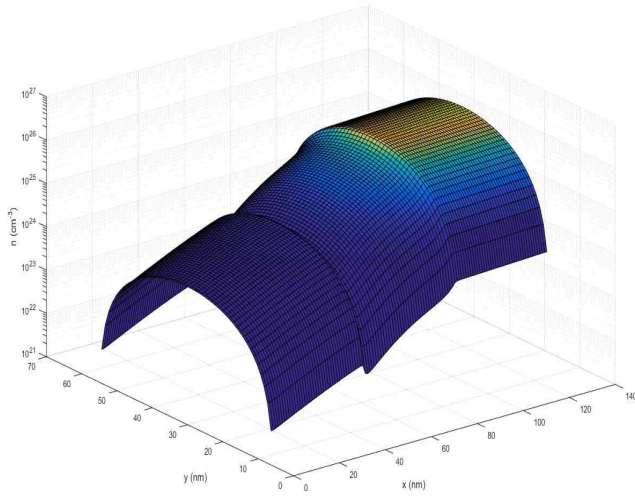
Electron density at $V_S = 0.5$ V and $V_G = 0.1$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.91$; $m_{zz} = 0.19$



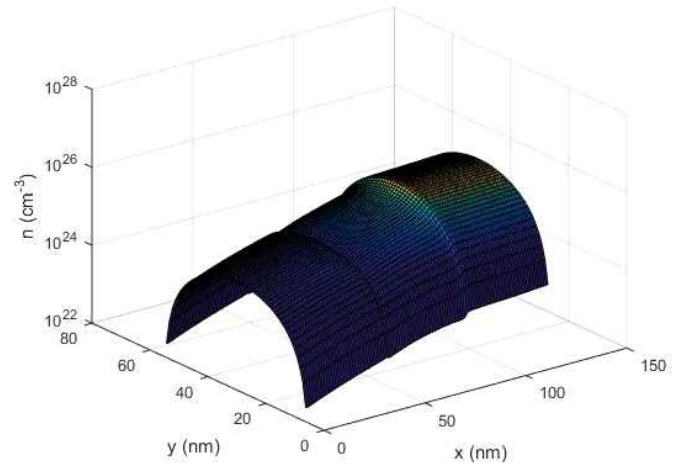
Electron density at $V_S = 0.1$ V and $V_G = 0.5$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.19$; $m_{zz} = 0.91$



Electron density at $V_S = 0.5$ V and $V_G = 0.5$ V
 $m_{xx} = 0.91$; $m_{yy} = 0.19$; $m_{zz} = 0.19$



Electron density at $V_S = 0.5$ V and $V_G = 0.5$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.91$; $m_{zz} = 0.19$



Electron density at $V_S = 0.5$ V and $V_G = 0.5$ V
 $m_{xx} = 0.19$; $m_{yy} = 0.19$; $m_{zz} = 0.91$